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EFS ID: 18922
Application ID: 10065277
Title of Invention: High-Power Pulsed Magnetron Sputtering
First Named Inventor: Roman Chistyakov
Domestic/Foreign Application: Domestic Application
Filing Date: 2002-09-30
Effective Receipt Date: 2002-10-16
Submission Type: Information Disclosure Statement
Filing Type: null
Confirmation Number: 5690
Attorney Docket Number: ZON-001
Digital Certificate Holder: cn=Kurt Rauschenbach, ou=Registered Attorneys, ou=Patent and Trademark Office, ou=Department of Commerce, o=U.S. Government, c=US
Certificate Message Digest: t51843ylio0aNtkdYFclHQ==





TRANSMITTAL FORM

Electronic Version 1.0.3

Stylesheet Version: 1.0

Submission Type: Information
Disclosure Statement

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Application Number: 10/065,277
Attorney Docket Number: ZON-001

High-Power Pulsed Magnetron Sputtering

First Named Inventor: Mr. Roman Chistyakov

SUBMITTED BY

Name: Dr. Kurt Rauschenbach
Registration Number: 40,137
Electronic Signature Mark: kr Date Signed: 20021016

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Attached Files:

us-information-disclosure-statement

zon-001-idsids.xml

Comments:

Electronic Information Disclosure Statement




High-Power Pulsed Magnetron Sputtering

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Application: 
10/065277

Confirmation: 5690

Applicant(s): Roman Chistyakov

Docket Number: ZON-001







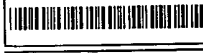

Group Art Unit: 1753

Examiner: Unassigned

search string: (5015493 or 6296742 or 6413382 or 6436251 or 5875207 or 4953174 or 6296742 or 4965248).pn.

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

| init | Citation No. | Patent Number | Date | Bar Code | Patentee | Class | Subclass |
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Signature

| Examiner Name | Date |
|---------------|------|
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